Scanning Angle Raman Spectroscopy of Poly(3-hexylthiophene)-Based Films on Indium Tin Oxide, Gold, and Sapphire Surfaces

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Supporting Information

ABSTRACT: Interest in realizing conjugated polymer-based films with controlled morphology for efficient electronic devices, including photovoltaics, requires a parallel effort to characterize these films. Scanning angle (SA) Raman spectroscopy is applied to measure poly(3-hexylthiophene) (P3HT):phenyl–C61–butyric acid methyl ester (PCBM)-blend morphology on sapphire, gold, and indium tin oxide interfaces, including functional organic photovoltaic devices. Nonresonant SA Raman spectra are collected in seconds with signal-to-noise ratios that exceed 80, which is possible due to the reproducible SA signal enhancement. Raman spectra are collected as the incident angle of the 785 nm excitation laser is precisely varied upon a prism/sample interface from approximately 35 to 70°. The width of the ~1447 cm⁻¹ thiophene



C=C stretch is sensitive to P3HT order, and polymer order varied depending on the underlying substrate. This demonstrates the importance of performing the spectroscopic measurements on substrates and configurations used in the functioning devices, which is not a common practice. The experimental measurements are modeled with calculations of the interfacial mean square electric field to determine the distance dependence of the SA Raman signal. SA Raman spectroscopy is a versatile method applicable whenever the chemical composition, structure, and thickness of interfacial polymer layers need to be simultaneously measured.

KEYWORDS: conjugated polymer films, P3HT, phenyl-C61-butyric acid methyl ester, PCBM, thin film characterization, Raman spectroscopy

1. INTRODUCTION

Conjugated organic polymers and molecules with conducting properties are suitable for use in electronic devices, such as light-emitting diodes and photovoltaic devices.¹ The performance of these organic-based devices highly depends on the ordering of molecules at the interface. For example, blending poly(3-hexylthiophene) (P3HT) with the fullerene derivative phenyl-C61-butyric acid methyl ester (PCBM) forms a socalled "bulk heterojunction" system.²⁻⁵ The bulk heterojunction system takes advantage of phase segregation between P3HT donor and PCBM acceptor to facilitate charge separation and transport while still allowing for a film thickness sufficient for high optical absorption. Increased P3HT crystallization has been shown to increase the charge carrier mobility, optical absorption, and output efficiencies in organic photovoltaic devices.^{6,7} Therefore, understanding the molecular ordering of P3HT is critical when making use of these thin films as active layers in various electronic devices.

The P3HT:PCBM morphology depends on several experimental factors including mixture composition, solvent, and processing steps.⁸ To date bulk heterojunctions have been fabricated by various processes including postproduction thermal annealing and slow growth solvent annealing.⁹ Slow growth solvent annealing involves storing the active layer in a restricted volume directly after spin coating to allow the solvent to naturally evaporate.¹⁰ It has been demonstrated that slow evaporation of the solvent leads to a dramatic improvement in the performance of the corresponding solar cells.¹¹ The polymer thickness in functioning devices can range from 11 nm to a few hundred nanometers depending on the application requirements.¹² Unfortunately, consistent control over donor:-acceptor morphology at a variety of spatial scales, and thus efficient device performance, has proven to be a challenge. Over the past decade, incremental improvements in materials processing and the emergence of new materials have led to

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Figure 1. Schematic of the (A) scanning-angle Raman spectroscopy format used to measure P3HT-based films on sapphire, gold or ITO substrates, compared to (B) conventional, 180-degree backscattering Raman geometry. In the scanning angle Raman format, the incident angle of light relative to the axis shown by the dotted line is varied. The coordinate system is used throughout the discussion.

power conversion efficiencies of organic photovoltaic cells ranging from $\sim 4-9\%$.^{13,14}

Raman spectroscopy is a nondestructive vibrational technique that can be used to probe molecular information and P3HT film morphology.¹⁵ The ~1447 cm⁻¹ C==C thiophene ring stretch is sensitive to the extent of π -electron delocalization along the P3HT chain axis, and monitoring the Raman peak shape and position can give insight into morphology and crystallinity.^{16,17} Since P3HT's thiophene rings are more closely stacked with greater order when the polymer is highly crystalline, there is a narrowing of the ~1447 cm⁻¹ peak. Many studies report the full width at half-maximum (fwhm) of the ~1447 cm⁻¹ peak as a measure of P3HT crystallinity.^{16,18-20} High signal-to-noise ratio Raman spectra of nanometer thin films and accurate peak fitting algorithms are required to accurately correlate changes in Raman peak shape with polymer morphology.

Raman spectroscopy has been used to study P3HT and bulk heterojunction systems.^{10,21–24} Recently, Tosi and co-workers investigated how the C=C Raman mode can be used as a tool to quantify the degree of molecular order of P3HT in the P3HT:PCBM-blend films using resonance, preresonance and nonresonant conditions.²⁰ The degree of molecular order measured by Raman spectroscopy correlated well with the performance of the corresponding solar cells. Resonance Raman imaging has also been applied to spatially map morphology dependent variations in P3HT:PCBM-blend films.²⁵

In this paper we show the application of scanning angle (SA) Raman spectroscopy for studying P3HT molecular order on various substrates relevant for organic electronic devices. The SA Raman configuration and conventional 180° backscattering geometry are compared schematically in Figure 1. The SA Raman configuration generates a large mean square electric field (MSEF) within the polymer film at defined incident angles. This increases the generated Raman scattering compared to conventional Raman spectroscopy. SA Raman spectra of P3HT and P3HT:PCBM films have 80 to 230 signalto-noise ratios with 30-s acquisition times and approximately 20 mW laser power at nonresonant conditions. The enhanced signal, without the use of resonant excitation, enables the characterization of changes in the C=C thiophene peak shape in functional photovoltaic devices where the P3HT:PCBMblend is sandwiched between semitransparent layers. We show

the degree of P3HT order varies for indium tin oxide, gold and sapphire substrates, and demonstrate the need to perform Raman measurements in the functional device to obtain relevant morphology information.

2. EXPERIMENTAL SECTION

2.1. Film Preparation. Thirty mg/mL P3HT or 30 mg/mL PCBM (ChemSci technologies Inc., Belvidere, IL) were dissolved in 1,2-dichlorobenzene and stirred at 850 rpm on a hot plate at a temperature of 60 °C for 24 h to make the active layer solution. All films were prepared in a glovebox filled with nitrogen. The solutions were filtered using a glass syringe to avoid contamination²⁶ and a 0.2 μ m filter (Millipore, Billerica, MA). After filtration the films were spin coated (Specialty Coating Systems Inc., Indianapolis, IN) onto a clean 25.4 mm sapphire disc (Meller optics, Providence, RI) or onto a sapphire disc with 50 nm gold (GWC technologies, Madison, WI or Center for Nanophase Materials Sciences, Oak Ridge National Laboratory). The spin-coating speeds were 600 and 500 rpm for P3HT and PCBM, respectively. The remaining solvent was allowed to evaporate completely for 1 h after spin-coating. Subsequently, P3HT:PCBM (1:1 ratio, 8.5 mg/mL of each material in dichlorobenzene) were spin coated on sapphire or 50 nm gold substrates at 550 rpm. Again, the remaining solvent was allowed to evaporate completely for 1 h.

A photovoltaic device was prepared by depositing approximately 100 nm of indium tin oxide (ITO) onto the sapphire substrate under RF plasma deposition conditions (225 °C, 90 W, 5 mT). Poly(3,4-ethylenedioxythio-phene):poly(styrenesulfonate) (PEDOT:PSS) (H.C. Stark, Newton, MA) was spin coated on the ITO side of the substrate at 4000 rpm for 60 s with an approximate final thickness of 30 nm. The P3HT:PCBM blend (20 mg/mL) in 1,2-dichlorobenzene solvent was then spin coated at 500 rpm for 60 s and the remaining solvent was allowed to evaporate completely for 1 h. The final P3HT:PCBM blend layer had a thickness of approximately 100 nm as previously measured by atomic force microscopy (AFM). Lastly where noted, an ~150 nm aluminum cathode was thermally evaporated at a rate <5 Å/s under a 1×10^{-6} mBar vacuum.

2.2. SA Raman Measurements. SA Raman spectroscopy experiments were performed using a previously described instrument.²⁷ The instrument is capable of recording Raman spectra in the incident angle range of $28.00-74.00^{\circ}$ with a 0.05° incident angle resolution. Raman spectra were collected in 1° increments at the sapphire and ITO interfaces and between 0.05 (close to the plasmon waveguide resonance angle) to 1 degree at the gold interface. Incident excitation was from a 785-nm laser with 21 mW measured at the sample unless otherwise noted. The beam was ~200 μ m in diameter at the sample interface. A 10× magnification objective was used to collect the Raman scattering. Immersion oil (Cargille Laboratories, Cedar

Grove, NJ, n = 1.7800) was used to ensure optical contact between a sapphire prism and the sapphire substrate on which the P3HT-based films were formed. A half-wave plate in the excitation path was used to control the polarization of the incident light at the sample interfaces. All SA Raman spectra were acquired with a 30-s acquisition time unless otherwise noted.

2.3. Absorption, Thickness, and AFM Film Characterization. Absorption spectra were recorded using an Agilent 8453 UV–visible spectrophotometer (Santa Clara, CA). The absorption spectra were recorded immediately following the Raman measurements. P3HT and P3HT:PCBM blend thicknesses on sapphire and gold were determined using a F20 thin film measurement system (Filmetrics, San Diego, CA) in reflective mode. The standard deviation was calculated from three replicate measurements from three different locations at or near the center of the film after absorption measurements were performed.

2.4. Mean Square Electric Field (MSEF) Calculations. A 3D-finite-difference-time-domain (FDTD)-based simulation (EM Explorer, San Francisco, CA) was used to calculate the MSEF generated in the polymer layer and throughout the interface. The calculations assumed all individual layers had a constant index of refraction. The indices of refraction used for all calculations at 785 nm were: sapphire prism ($n_{p-polarization} = 1.764$, $n_{s-polarization} = 1.753$), ITO (n = 1.858, k = 0.0116), P3HT (n = 1.710, k = 0.006), PEDOT:PSS (n = 1.44, k = 0.0544), P3HT:PCBM blend (n = 2.010, k = 0.003), gold (n = 0.16, k = 4.71) and air (n = 1.000).^{28–34} A Yee cell size of 5 nm was used for all FDTD simulations. The angular resolution used for the calculations was 0.10°. The polymer and substrate layer thicknesses used in the FDTD calculations are provided in the figure legends.

Data Analysis. All data analysis was performed using the software IGOR Pro 6.1. Signal-to-noise ratios were calculated as the maximum of the ~1447 cm⁻¹ peak intensity after background subtraction divided by the standard deviation from the 1600 to 1625 cm⁻¹ region of the spectrum where no analyte peaks were present. Peak fwhms were measured using the "Multipeak fitting 2" algorithm in IGOR Pro 6.1 using a Gaussian peak shape and linear baseline. The MSEF graphs were compiled in Matlab v.7.12.0 using a surface plot.

3. RESULTS AND DISCUSSION

SA Raman spectroscopy has previously been used to measure polystyrene films at sapphire, gold and silica interfaces.^{35–37} The goal of the current work is to apply SA Raman spectroscopy to measure thin film semiconducting polymers on sapphire, gold and ITO substrates, focusing on the variability of P3HT order at these interfaces. The P3HT, PCBM, and P3HT:PCBM Raman signal at each interface as a function of incident angle is first discussed, followed by a discussion of P3HT morphology.

SA Raman Spectra of P3HT, PCBM, and 1:1 P3HT:PCBM on Sapphire. The Raman spectra of P3HT, PCBM, and P3HT:PCBM on sapphire are shown in Figure 2 with the conventional 180° backscattering configuration (Figure 2A) and the scanning-angle configuration (Figure 2B). The Raman spectra plotted in Figure 2B were collected at a 35.00° incident angle, which is the angle that produced the largest Raman signal for all three samples. This is close to the sapphire/air critical angle of 34.59 degrees, as expected. With all experimental conditions the same except for the excitation geometry, it is evident that the SA Raman format enhances the Raman signal over the backscattering geometry. Compared to the backscattering geometry, the SA Raman spectra collected at 35.00° have a 21×, 11×, or 4× larger peak area for P3HT (1447 cm⁻¹), PCBM (1465 cm⁻¹), and P3HT:PCBM (1447 cm⁻¹), respectively.

The absorption spectra shown in Figure 3 confirm that the 785 nm excitation wavelength corresponds to nonresonant



Figure 2. Raman spectra of P3HT (black), PCBM (dotted black), and a 1:1 mixture of P3HT:PCBM (gray) on sapphire. The Raman spectra were acquired with (A) 180° backscattering Raman spectroscopy or with (B) SA Raman spectroscopy at an incident angle of 35.00° . The incident power at the sample (measured without a prism) was 21 mW for P3HT and P3HT:PCBM and 205 mW for PCBM. The peaks from the sapphire prism that appear in the SA Raman spectra are marked with asterisks (*).



Figure 3. Absorption spectra of P3HT (black), PCBM (dotted black), and 1:1 P3HT:PCBM (gray) films spread on a sapphire substrate.

conditions for both P3HT and PCBM. To record a PCBM Raman spectrum, we required approximately an order of magnitude higher laser power compared to the 21 mW power that was used to collect the P3HT and P3HT:PCBM spectra. Therefore, the conditions used to acquire P3HT spectra have minimal contribution from PCBM despite the similar Raman shifts of the main PCBM (~1465 cm⁻¹) and P3HT (~1447 cm⁻¹) peaks. All Raman peak locations and assignments are shown in the Supporting Information, Table S1.

The SA Raman spectra collected at selected incident angles for P3HT and PCBM on sapphire are shown in Figure 4. The signal for the P3HT:PCBM-blend is approximately half that of the pure P3HT film, which is expected given the 1:1 composition of the P3HT:PCBM blend. Although the Raman signal of the P3HT:PCBM blend decreases with increasing



Figure 4. (A) Schematic of the SA Raman interface used to collect the data shown in B and C. SA Raman spectra at the indicated incident angles for (B) P3HT and (C) 1:1 P3HT:PCBM deposited on a sapphire substrate.

incident angle, the Raman signal for pure P3HT decreases until the incident angle is scanned to approximately 60°, and then increases at larger incident angles.

MSEF calculations show the distance dependence in the Z direction (Figure 1) of the Raman signal, and aid in the interpretation of the Raman signal as the incident angle of excitation is varied (Figure 5). The expected Raman signal is proportional to the integrated MSEF across the entire polymer thickness (i.e., starting on the left of the plot and ending at the vertical white line). The MSEF plots shown in Figure 5 were calculated using the polymer thickness measured by AFM analysis on the samples used to generate the Raman data in Figure 4. The standard deviation for these AFM measurements was 100 nm. Because the independent measurement of the film thickness by AFM is rather uncertain, only general trends between the experimental Raman data and the MSEF calculations will be considered.

Analysis of the MSEF within the polymer layer indicates that the Raman signal for the P3HT:PCBM films should decrease as the incident angle is scanned beyond 35 degrees, whereas the P3HT films should have a maximum near 35 degrees and a second maximum near 65 degrees (Figure 5). This agrees with the experimental Raman spectra as demonstrated by the subset of data shown in Figure 4. The MSEF plots reveal information regarding the spatial profile in the Z direction: the experimental Raman signal is generated across the entire polymer film, but not uniformly throughout the polymer film at all incident angles. Polymer located in the region having the highest MSEF will contribute the most to the experimental Raman signal. Although the calculated MSEF is large in the bulk air layer (i.e.,



Figure 5. Calculated MSEF as a function of distance and incident angle for the interface: (A) 0-1000 nm sapphire/1000-1230 nm P3HT:PCBM/1230-6000 nm air, (B) 0-1000 nm sapphire/1000 to 1300 nm P3HT/1300 to 6000 nm air. The MSEF in the sapphire layer (0-1000 nm) and the majority of the air layer (greater than 1500 nm) are omitted for clarity. The calculated plots show the expected distance dependence of the experimental Raman signal in the Z direction. The thicknesses of 230 nm P3HT:PCBM and 300 nm P3HT represent the sample thicknesses determined by AFM for the samples used to generate the data plotted in Figure 4.

to the right of the vertical white line), this will not affect the experimental Raman spectrum because the Raman signal of air is negligible. The MSEF's spatial profile throughout the interface depends on many factors including polymer thickness, incident angle, indices of refraction, and excitation wavelength.

In contrast to the spatial profile of the Raman signal in the Z direction, the spatial profile in the X/Y direction (Figure 1) is controlled by the diameter of the laser beam at the sapphire/sample interface. For the data presented herein the beam diameter is 200 μ m, which is sufficiently large to average the signal from any lateral inhomogeneities in the polymer film.

SA Raman Spectra of P3HT and 1:1 P3HT:PCBM on Gold. Chemical and structural analysis of conducting polymers on metals has seen an increase in demand with the rise of light emitting and light harvesting devices such as nanoscale lasers, cavities and antennas.³⁸⁻⁴⁰ The MSEF calculations for P3HT or P3HT:PCBM films on a gold substrate (Figure 6) reveal a very different pattern compared to the MSEF calculated for a sapphire substrate (Figure 5). At specific incident angles there is a large MSEF increase in the polymer layer corresponding to the angles where plasmon waveguide resonances (PWRs) are excited. At these incident angles, the largest Raman scattering is predicted. The incident angle associated with exciting PWRs depends on properties of the gold film and similar properties discussed above for the sapphire substrate. In contrast to rough metal films, smooth metal films produce MSEFs that are reproducible and easily quantified. Importantly, when other experimental variables are known, the pattern of the Raman signal as a function of incident angle provides an accurate measure of polymer thickness.³⁵

Panels A and B in Figure 6 show the calculated MSEF for a 512 nm 1:1 P3HT:PCBM film and a 700 nm P3HT film on a



Figure 6. Calculated MSEF as a function of distance and incident angle for the interface: (A) 0-1000 nm sapphire/1000-1050 nm gold/1050 to 1562 nm P3HT:PCBM/1562-6000 nm air (B) 0-1000 nm sapphire/1000-1050 nm gold/1050-1750 nm P3HT/1750-6000 nm air. The MSEF in the sapphire layer (0-1000 nm) and the majority of the air layer (greater than 2500 nm) are omitted for clarity. The calculated plots show the predicted incident angles that will generate the largest SA Raman scattering, which can be used to measure polymer thickness, and the distance dependence of the Raman signal in the Z direction. The thicknesses 512 nm P3HT:PCBM and 700 nm P3HT provided the best fit to the experimental SA Raman data in Figure 7.

gold substrate. These polymer thicknesses best fit the SA Raman data represented in Figure 7 (only a subset of spectra are shown for clarity). Optical interferometry performed on the same polymer films generated thickness values of 570 ± 50 nm and 830 ± 40 nm, respectively. Based on previously published work, there is an average 3% difference between polystyrene thickness measured by SA Raman spectroscopy and optical interferometry.³⁵ It is reasonable that the lack of agreement between the two measurement techniques for the P3HT:PCBM film represents variability in roughness at the probed locations. A 10 μ m \times 10 μ m AFM image of the P3HT:PCBM film had a z-range roughness of 72 nm (see the Supporting Information, Figure S1), which supports this hypothesis. For a 43.00° incident angle, the Raman signal generated in the 700 nm P3HT film is spatially uniform across the entire polymer thickness based on the MSEF plots, whereas a more complex spatial pattern in the Z direction is expected for the Raman signal of the 512 nm P3HT:PCBM film at 40.90 degrees (Figure 6).

SA Raman Spectra of 1:1 P3HT:PCBM on Sapphire/ ITO/PEDOT:PSS. It is possible to measure the SA Raman spectrum of P3HT:PCBM films in functional organic photovoltaic devices. MSEF calculations of P3HT:PCBM on an sapphire/ITO/PEDOT:PSS interface were performed using ppolarized excitation (Figure 8A) or s-polarized excitation (Figure 8B). The MSEF distribution plot predicts 2.5× more Raman scattering will be generated within the P3HT:PCBM film with s-polarized excitation compared to p-polarized excitation at 60.00 degrees. In addition p-polarized excitation is predicted to generate significant Raman scattering within the



Figure 7. (A) Schematic of a sapphire/gold/polymer/air interface. Scanning angle Raman spectra at the indicated incident angles for (B) P3HT and (C) 1:1 P3HT:PCBM deposited on a gold substrate.



Figure 8. Calculated MSEF for the interface 0–1000 nm sapphire/ 1000–1100 nm ITO/1100–1130 nm PEDOT:PSS/1130–1230 nm P3HT:PCBM/1230–6000 nm air with (A) p- and (B) s-polarized excitation. The MSEF in the sapphire layer (0–1000 nm) and the majority of the air layer (greater than 1300 nm) are omitted for clarity. The MSEF distribution plot predicts that more Raman scattering will be generated in the P3HT:PCBM film with s-polarized excitation while p-polarized excitation will generate strong, unwanted Raman scattering in the PEDOT:PSS film.

30 nm PEDOT:PSS film. PEDOT may spectrally interfere with the P3HT signal given the similar chemical functionalities in both polymers.

Another consideration when selecting excitation-polarization conditions using the SA Raman format is the orientation of the generated electric field at the interface. S-polarized excitation generates a MSEF component in the Y direction and ppolarized excitation generates MSEF components in the Z and to a minor extent X directions. In the case of thiophene, both the C–C and C==C stretches are depolarized bands.⁴¹ With all of the above considerations, it is optimal to use s-polarized excitation for the experimental measurements on the sapphire/ ITO/PEDOT:PSS interface to maximize the P3HT contribution to the Raman spectrum.

Raman spectra collected at a 60.00° incident angle are shown in Figure 9 for a sapphire/ITO/PEDOT:PSS/P3HT:PCBM



Figure 9. (A) Schematic of a sapphire/ITO/PEDOT:PSS/1:1 P3HT:PCBM/air interface. (B) Raman spectra of 1:1 P3HT:PCBM with Al coated over the polymer (gray) and without Al (black). The Raman spectra were collected at an incident angle of 60.00° with spolarized excitation and 21 mW (black) or 40 mW (gray) laser power.

and sapphire/ITO/PEDOT:PSS/P3HT:PCBM/Al device, the latter represents a functional photovoltaic device. Since the aluminum layer is semitransparent, the laser power was increased approximately 2× to record the spectrum of this sample. Surprisingly, the aluminum layer does not significantly degrade the quality of the Raman spectrum, and reduces the spectral background compared to the sample without the aluminum layer. This indicates that the SA Raman measurements can be obtained on functional organic photovoltaic devices, which is beneficial to obtaining a direct correlation between polymer morphology and device performance.

Molecular Order of P3HT and 1:1 P3HT:PCBM Films. Addition of PCBM to the P3HT film has been shown to increase P3HT molecular disorder.⁸ The degree of P3HT molecular order in the P3HT:PCBM films is well correlated with the performance of the corresponding photovoltaic device. SA Raman spectroscopy is ideally suited to measure the effect of sapphire, gold or ITO/PEDOT:PSS substrates on P3HT molecular order using the same metrics described for Raman spectra collected with traditional illumination schemes. The fwhm of the ~1447 cm⁻¹ peak is expected to decrease, and device efficiency increase, with increasing P3HT order or crystallinity. For all collected SA Raman spectra, the ~1447 cm^{-1} C=C stretching region of P3HT was fit to a Gaussian function. The use of a Gaussian function is suitable for solid samples when molecular motion is minimal.⁴² Example Gaussian fits to the Raman spectra are shown in the Supporting Information, Figure S2. Although there was slight asymmetry between the $\sim 1447 \text{ cm}^{-1}$ Raman peaks in all spectra and the corresponding Gaussian fit, suggesting the existence of at least two overlapping peaks, fitting this spectral region to two peaks resulted in large uncertainties in the 6 required fit parameters. Given the small residual when using a Gaussian fit (see the Supporting Information, Figure S2), the \sim 1447 cm⁻¹ C=C stretching region was fit to single Gaussian function and the fwhm calculated from the fit for spectra collected at each interface and incident angle. There was no correlation between fwhm and incident angle, and the measurement reproducibility was excellent (see the Supporting Information, Figure S3), thus the average fwhm for all incident angles was calculated (Table 1).

Table 1. Average Raman Shift and FWHM of the C=C Stretch and the Signal-to-Noise Ratio for the Spectrum Collected at the Indicated Incident Angle That Produced the Largest Raman Signal

interface ^{<i>a</i>}	C=C Raman shift (cm ⁻¹)	C=C Raman peak fwhm (cm ⁻¹)	signal-to- noise ratio (incident angle, deg)
sapphire/P3HT	1446.2 ± 0.5	26.0 ± 0.2	200 (35.00)
sapphire/P3HT:PCBM blend	1446.1 ± 0.3	25.8 ± 0.4	150 (35.00)
sapphire/Au/P3HT	1448.4 ± 0.4	26.0 ± 0.2	230 (43.00)
sapphire/Au/P3HT:PCBM blend	1448.7 ± 0.3	29 ± 1	80 (41.60)
sapphire/ITO/PEDOT:PSS/ P3HT:PCBM blend S-polarization	1446.2 ± 0.6	27.8 ± 0.8	150 (60.0)
sapphire/ITO/PEDOT:PSS/ P3HT:PCBM blend/Al S-polarization 40 mW	1450 ± 2	31 ± 1	155 (60.0)

^aThe incident laser was p-polarized and 21 mW at the sample unless otherwise noted.

All of the samples included in this study used slow growth solvent annealing post processing. For the sapphire substrate, there is no evidence for an increase in P3HT disorder in the P3HT:PCBM blend. The fwhm of the C=C peak is approximately 26 cm⁻¹ with and without PCBM added to the P3HT. This indicates that PCBM does not increase P3HT disorder on the sapphire substrate when slow growth solvent annealing is used as a post processing step. This conclusion is supported by the absorption spectrum in Figure 2.²² On the gold interface, however, the fwhm increases from 26.2 \pm 0.2 (P3HT) to 29 ± 1 (P3HT:PCBM) cm⁻¹. This indicates P3HT order on a gold substrate decreases when PCBM is added. Tsoi et al. reported the fwhm for the C=C stretch of a P3HT:PCBM film using 785 nm excitation before and after annealing the sample to increase P3HT order.²⁰ Before annealing the fwhm was 39 cm⁻¹ and after annealing the fwhm decreased to 26 cm⁻¹. This supports the conclusion reported herein that P3HT in the P3HT:PCBM blend on the gold substrate has increased disorder, however not to the same

extent expected for a sample that had no post processing treatments. Comparing the two films on the sapphire/ITO/ PEDOT:PSS substrate, the additional processing required to form the aluminum electrode on the polymer films increases P3HT disorder compared to the film without the aluminum film.

These conclusions were confirmed with two additional experiments: AFM on selected samples and resonant Raman spectroscopy using traditional 180° backscattering illumination. Raman spectroscopy with 488 nm excitation corresponds to resonance Raman conditions (Figure 3). Resonance Raman spectra showed a ~1447 cm⁻¹ fwhm ratio between the P3HT:PCBM and P3HT samples of 1.06 \pm 0.03 with a sapphire substrate and 1.15 \pm 0.03 with a gold substrate (see the Supporting Information, Figure S4 and Table S2). This compares well to the ratio collected using SA Raman spectroscopy (0.99 \pm 0.03 for sapphire and 1.12 \pm 0.04 for gold); and validates the SA Raman measurements showing relative disorder for the P3HT:PCBM film on a gold substrate. Resonance conditions are not required to measure P3HT order using SA Raman spectroscopy.

AFM images were collected to measure the surface roughness in a P3HT film on sapphire and a P3HT:PCBM film on gold. The amount of P3HT ordering can be determined by the surface roughness.⁴³ The P3HT film on sapphire had an RMS roughness of 19 nm, and the P3HT:PCBM blend on gold had an RMS roughness of 8.3 (see the Supporting Information, Figure S1). When the P3HT order increases upon solvent vapor annealing, Miller et al. report the AFM images transformed from featureless to show 10 to 20 nm surface clusters; and the device with the higher surface roughness exhibited higher device efficiencies.¹⁹ Therefore, it can be concluded from the AFM images that there is more ordering of P3HT on sapphire than exhibited by the polymer in the P3HT:PCBM blend on gold. This is consistent with the conclusion drawn from analyses of the fwhm of the ~1447 cm⁻¹ peaks. SA Raman spectroscopy indicated the P3HT exhibited relative order on sapphire and relative disorder in the P3HT:PCBM blend on the gold film.

The signal-to-noise ratio for the spectrum that produced the largest Raman signal was calculated at each interface (Table 1). All spectra were collected with a 30 s acquisition time, resulting in signal-to-noise ratios of at least 80. Significantly shorter acquisition times can be used while still collecting spectra of sufficient quality for quantitative analysis. It should be noted that the signal-to-noise ratio can decrease significantly if the Raman spectra are not collected at the optimum incident angle, which highlights the importance of either scanning the range of incident angles or using MSEF calculations to determine optimal angles for data collection.

4. CONCLUSIONS

SA Raman spectroscopy is a powerful technique for studying molecular order in conjugated polymer and blend films. By utilizing SA Raman spectroscopy one can measure enhanced Raman signals, film thickness, molecular order, and one can determine where the Raman scattering is generated within the polymer film when combined with MSEF calculations. This technique is currently being used to measure other semiconducting photovoltaic materials such as PCDTBT (poly[N-9'-heptadecanyl-2,7-carbazole-*alt*-5,5-(4',7'-di-2-thienyl-2',1',3'-benzothiadiazole)]); and the SA Raman technique is being expanded to other excitation wavelengths.

ASSOCIATED CONTENT

S Supporting Information

Raman peak assignments, Gaussian fit curves and fit parameters to Raman peaks using 488 and 785 nm excitation wavelengths, replicate SA Raman spectra, and AFM images. This material is available free of charge via the Internet at http://pubs.acs.org

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Notes

The authors declare no competing financial interest.

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